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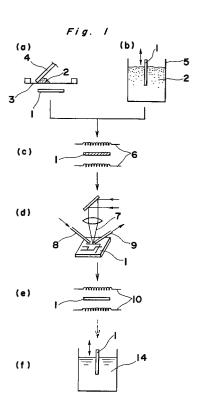
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## Method for manufacturing thick film circuit substrate.

© A method for manufacturing a thick film circuit substrate, has the steps of: coating paste (2) onto a substrate (1) to form a thick paste film; drying the paste film on the substrate (1); irradiating a laser beam (7) on the dried paste film to remove the paste film in an area, where the laser beam (7) is irradiated, to form a film with a specified pattern; and baking the film with the pattern.





## **EUROPEAN SEARCH REPORT**

EΡ 90 11 6440

ategory	Citation of document with indic of relevant passa		Relevant to claim	CLASSIFICATION OF THE APPLICATION (Int. Cl.5)
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<b>A</b>	PATENT ABSTRACTS OF JAPAN vol. 12, no. 77 (E-589)10 March 1988 & JP-A-62 216 259 ( FWJITSW ) 22 September 1987 * abstract *		5	
	The present search report has been	-		Premiare
Place of search THE HAGUE		Date of completion of the search 11 MARCH 1992	PIIN	Examiner L. A. T.

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